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Book review

Advances in Physical Organic Chemistry Vol. 16; edited by V. Gold and D. Bethell, Academic Press, London/New York/San Francisco, 1978, vii + 184 pages, £16.30, \$35.30.

This addition to the excellent series will be reviewed only briefly here because it contains little of specific interest to organometallic chemists. The reviews presented are as follows: Diffusion control and pre-association in nitrosation, nitration and halogenation (J.H. Ridd, 49 pages); Directive effects in gas-phase radical additive reactions (J.M. Tedder and J.C. Walton, 36 pages); Methyl transfer reactions (J. Albery and M.M. Keevoy, 71 pages); Electrical conduction in organic solids (J.O. Williams, 79 pages); Nuclear magnetic relaxation: recent problems and progress (S. Berger, 27 pages). All appear well written and authoritative. My own special interest led me to pay particular attention to the timely chapter by J.H. Ridd, and I found this impressively comprehensive, concise, and clear.

As always with this series, the volume represents excellent value.

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